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Electronic Version v1.1

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Title of
Invention

LOW-K DIELECTRIC MATERIAL BASED UPON CARBON NANOTUBES AND METHODS OF FORMING SUCH LOW-K DIELECTRIC MATERIALS

Application Number:

Date:

First Named Applicant:

Toshiharu Furukawa

Confirmation Number:

Attorney Docket Number:

BUR920040152US1

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Documents being submitted:	Files
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us-request	BUR920040152US1-usrequ.xml
	us-request.dtd
	us-request.xsl
us-assignment	BUR920040152US1-usassn.xml
	us-assignment.xsl
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	BUR920040152ASSIGN1.tif
	BUR920040152ASSIGN2.tif
us-fee-sheet	BUR920040152US1-usfees.xml
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	us-fee-sheet.dtd
us-declaration	BUR920040152DEC1.tif
us-declaration	BUR920040152DEC2.tif
application-body	BUR920040152ABX.xml
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	isotech.ent
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	mmlextra.ent	
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abstract-pdf	BUR920040152ABX-abst.pdf	
claims-pdf	BUR920040152ABX-clms.pdf	
description-pdf	BUR920040152ABX-desc.pdf	
drawings-pdf	BUR920040152ABX-draw.pdf	
Comments		

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